

UNITED STATES DEPARTMENT OF COMMERCE

United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS

Washington, D.C. 20231

FIRST NAMED INVENTOR ATTORNEY DOCKET NO. APPLICATION NO. FILING DATE 09/271,447 03/18/99 SATOH Н

400113/SAHIN

IM52/0712

EXAMINER

LEYDIG VOIT & MAYER 700 13TH STREET NW SUITE 300 WASHINGTON DC 20005-3960

CLEVELAND, M **ART UNIT** PAPER NUMBER 1762

DATE MAILED:

07/12/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

		Application N	lo.	Applicant(s)	
	▼	09/271,447		SATOH, HIROAKI	
	[→] Office Action Summary	Examiner		Art Unit	
		Michael Clev	eland	1762	
	- The MAILING DATE of this communication app	pears on the co	ver sheet with the c	orrespondence ad	idress
Period fo	r Reply	VIC CET TO E	SYDIRE 3 MONTH(S) FROM	
THE N - Exten after S - If the - If NO - Failur - Any re earne	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. sions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a rep period for reply is specified above, the maximum statutory period e to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailine of patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, I ly within the statutory will apply and will ex	nowever, may a reply be timer minimum of thirty (30) day pire SIX (6) MONTHS from the become ABANDONE	nely filed s will be considered time the mailing date of this of D (35 U.S.C. § 133).	ly. communication.
Status	Responsive to communication(s) filed on <u>06</u>	June 2001 .			
1)⊠		his action is no	n-final.		
2a)☐	or this application is in condition for allow	ance except for	or formal matters, p	rosecution as to t	he merits is
3)□	closed in accordance with the practice under	r Ex parte Qua	yle, 1935 C.D. 11,	453 O.G. 213.	
Dispositi	on of Claims				
4)	Claim(s) 1-9 is/are pending in the application	1.			
	4a) Of the above claim(s) 9 is/are withdrawn f	rom considera	tion.		
5)	Claim(s) is/are allowed.				
6)⊠	Claim(s) <u>1-8</u> is/are rejected.				
7)[Claim(s) is/are objected to.				
8)[Claim(s) are subject to restriction and	or election req	uirement.		
Applicat	ion Papers				
9)[The specification is objected to by the Examir	ner.		U. Suminos	
10)⊠	The drawing(s) filed on 18 March 1999 is/are:	a)⊠ accepted	or b) objected to D	oy the Examiner.	١
	Applicant may not request that any objection to	the drawing(s) b	e held in abeyance.	see 37 CFR 1.65(a	<i>).</i> iner
11)	The proposed drawing correction filed on	is: a) apr	oroved b) disapp	Toved by the Exam	arier.
	If approved, corrected drawings are required in		ce action.		
1	The oath or declaration is objected to by the I	Examiner.			
Priority	under 35 U.S.C. §§ 119 and 120		05 6	(a) (d) or (f)	
	Acknowledgment is made of a claim for fore	ign priority und	er 35 U.S.C. § 119	(a)-(u) or (i).	
а)⊠ All b)□ Some * c)□ None of:		ivad		
	1.⊠ Certified copies of the priority docume	ents have been	received in Applica	ation No	
	2. Certified copies of the priority docume	ents have been	received in Applica	wed in this Nation	al Stage
*	3. Copies of the certified copies of the paraphication from the International See the attached detailed Office action for a l	ist of the certifi	ed copies not recei	ved.	
141	Acknowledgment is made of a claim for dome	estic priority un	der 35 U.S.C. § 119	9(e) (to a provisio	nal application).
ļ	a) The translation of the foreign language Acknowledgment is made of a claim for dome	provisional app	olication has been r	eceived.	
Attachme					AL : (-)
2) \ No	tice of References Cited (PTO-892) tice of Draftsperson's Patent Drawing Review (PTO-948) ormation Disclosure Statement(s) (PTO-1449) Paper No(s	s) <u>7</u>	4) Interview Summ 5) Notice of Inform 6) Other:	ary (PTO-413) Paper al Patent Application	No(s) (PTO-152)
U.S. Patent an	d Trademark Office	Action Summar	v	P	art of Paper No. 8

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DETAILED ACTION

Election/Restrictions

1. Applicant's election with traverse of Group I, claims 1-8 in Paper No. 6 is acknowledged. The traversal is on the ground(s) that there is no serious burden on the Examiner. This is not found persuasive because a serious burden exists in the differing issues that are likely to arise during the prosecution of process and product claims.

The requirement is still deemed proper and is therefore made FINAL.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless —

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

3. Claims 1-7 are rejected under 35 U.S.C. 102(e) as being anticipated by Tanaka et al. (U.S. Patent 5,858,616, hereafter '616).

'616 teaches depositing a layer that is both an resin (A) composition layer (See col. 4, lines 36-45) and a photosensitive resin (B) composition layer (See col. 2, lines 26-34.) The resin composition includes (a) an acrylic resin is a copolymer with an acid value of 15-200 and a weight average molecular weight of 10,000-150,000 (col. 6, lines 46-59) and (b) a phosphor (i.e., a fluorescent material) (col. 2, lines 26-34). The composition is deposited in cells of a plasma display (col. 14, line 46-col. 15,line 7), exposed (col. 15, lines 8-50), developed (col. 15, lines 51-67), and baked (col. 16, lines 41-48; col. 17, lines 10-13).

Claims 2-5: The viscosity of the polymer composition is 1 to 500 Pa.s (i.e., 1000-500000 mPa.s). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have used polymers with similar viscosities to the desired viscosity in order to have reduced the need for viscosity adjusting additives. Such viscosity is controlled via the glass transition temperature of the acrylic polymer (col. 13, lines 17-29). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have optimized the glass transition temperature in order to have achieved the desired viscosity.

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Claims 4 and 6: The composition may contain a polymerization inhibitor (col. 13, lines 20-26).

Claim 5: The solvent may be a polyalkylene glycol (i.e., a polyhydric alcohol), such as those given in col. 12, lines 4-31).

Claim 6: The composition may contain an ethylenically unsaturated group (col. 7, lines 39-44).

Claim 7: The composition may contain a photopolymerization initiator (col. 2, lines 33-34).

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 1-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka '616 in view of Koike et al. (U.S. Patent 5,922,395, hereafter '395).

Tanaka '616 is described above. It does not teach that a photosensitive layer (B) is formed after a resin composition layer (A) is formed.

Koike '935 teaches two equivalent embodiments of forming phosphor layers for applications such as plasma display panels (col. 1, lines 7-9). In one (Figs. 1-2), a photosensitive phosphor composition is deposited in the cells of the display panel, exposed and developed (col. 7, lines 8-29). In the other, a phosphor composition layer (7) and a photoresist (i.e., a photosensitive resin) layer are applied. The photoresist layer is exposed, and both layers are developed (col. 8, line 42-col. 9, line 38).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have applied a photoresist layer, such as that of Koike '935's second embodiment, on top of the phosphor layer of Tanaka '616 before developing and exposure with the expectation of similar results because Koike '935 teaches the equivalence of depositing a

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photosensitive phosphor layer, and depositing a phosphor layer followed by a photoresist layer before development in the formation of plasma display panels.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michael Cleveland whose telephone number is (703) 308-2331. The examiner can normally be reached on 9-5:30 M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive Beck can be reached on (703) 308-2333. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 306-3186 for regular communications and (703) 306-3186 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

MBC

July 10, 2001

SHRIVE P. BECK

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700